			in
	Application No.	Applicant(s)	
Notice of Allowability	09/754,273	CHOI ET AL.	
	Examiner	Art Unit	
	Elizabeth Keaney	2882	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in to their appropriate communers (RIGHTS). This application is su	his application. If not incluication will be mailed in du	ıded ıe course. THIS
1. This communication is responsive to the amendment and	request for continued examina	ntion filled 5 April 2004.	
2. The allowed claim(s) is/are <u>1-15</u> .			
3. The drawings filed on <u>07 August 2003</u> are accepted by th	e Examiner.		
 4. Acknowledgment is made of a claim for foreign priority of a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 	re been received. re been received in Application	No	cation from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	" of this communication to file a MENT of this application.	reply complying with the	requirements
5. A SUBSTITUTE OATH OR DECLARATION must be submiNFORMAL PATENT APPLICATION (PTO-152) which give			NOTICE OF
6. ☐ CORRECTED DRAWINGS (as "replacement sheets") mu (a) ☐ including changes required by the Notice of Draftsper 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner	rson's Patent Drawing Review	,	
Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	1.84(c)) should be written on the	drawings in the front (not t	he back) of
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	osit of BIOLOGICAL MATER	RIAL must be submitted	. Note the
Attachment(s)			
1. Notice of References Cited (PTO-892)		rmal Patent Application (P	TO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)			
3. Information Disclosure Statements (PTO-1449 or PTO/SB/Paper No./Mail Date	7. ☐ Examiner's A	ail Date mendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's S	tatement of Reasons for A	llowance

9. Other ____.

U.S. Patent and Trademark Office PTOL-37 (Rev. 1-04)

of Biological Material

DETAILED ACTION

Receipt is acknowledged of the Amendment filled 5 February 2004 and the Request for Continued Examination filled 5 April 2004.

Claims 1,2 and 14 are directed to an allowable product. Pursuant to the procedures set forth in the Official Gazette notice dated March 26, 1996 (1184 O.G. 86), claims 2-13, directed to the process of making or using the patentable product, previously withdrawn from consideration as a result of a restriction requirement, are now subject to being rejoined. Claims 2-13 are hereby rejoined and fully examined for patentability under 37 CFR 1.104.

Since all claims previously withdrawn from consideration under 37 CFR 1.142 have been rejoined, the restriction requirement made in the Office action mailed on 12 March 2003 is hereby withdrawn.

Allowable Subject Matter

Claims 1-15 are allowed over the prior art.

The following is an examiner's statement of reasons for allowance:

Re claims 1,2,14 and 15: The best prior art of record discloses a field emission device comprising a substrate, a cathode, micro-tips having nano-sized surface features, a gate insulation layer and a gate electrode. However, the prior art fails to teach or fairly suggest a field emission device comprising a substrate, a cathode, micro-

Application/Control Number: 09/754,273 Page 3

Art Unit: 2882

tips having nano-sized surface features, a gate insulation layer and a gate electrode, wherein the mircor-tips and non-sized surface features are of a homogeneous material as claimed in claims 1 and 14. Claims 2 and 15 are allowable by virtue of their dependency.

Re claims 3-13: The best prior art of record discloses a method for fabricating a field emission device comprising forming a cathode, a gate insulation layer, a gate electrode and micro-tips having nano-sized surface features. However, the prior art fails to teach or fairly suggest a method for fabricating a field emission device comprising forming a cathode, a gate insulation layer, a gate electrode and micro-tips having nano-sized surface features, forming a carbonaceous polymer layer, etching the carbonaceous polymer layer so as to form nano-sized surface features on the micro-tip wherein the micro-tip and the nano-sized features are of a homogenous material as claimed in claims 3 and 12. Claims 4-11 and 13 are allowable by virtue of their dependency.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Art Unit: 2882

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

US Patent 6,632,114 discloses the current state of the art.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Elizabeth Keaney whose telephone number is (571)272-2489. The examiner can normally be reached on Monday-Thursday 5:30-4.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ed Glick can be reached on (571)272-2490. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DAVID V. BRUCE
PRIMARY EXAMINER

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